Fabrication of Photonic LPCVD Silicon-Nitride Waveguides

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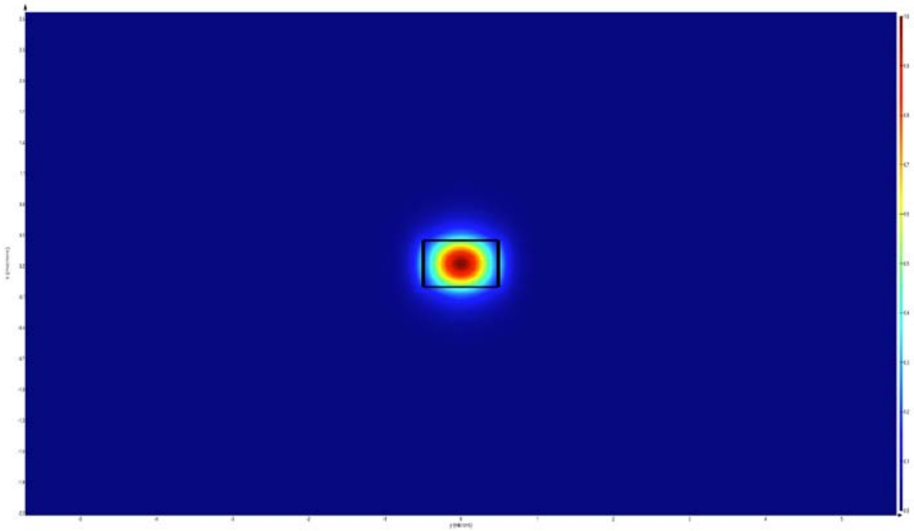
Overview

- Project Goals
- Photonics Overview
- Photomask Design
- Process Flow
- Results
- Acknowledgements

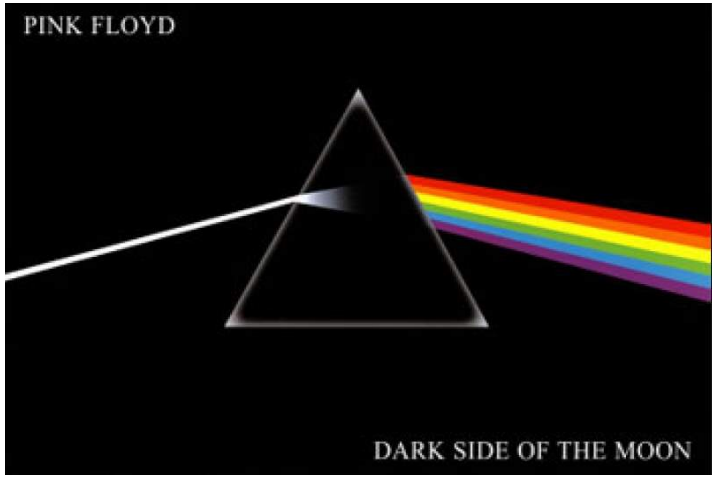
Project Goals

- Fabricate TE mode Nitride Waveguides using the tools available in the RIT SMFL Cleanroom
  - Amorphous silicon waveguides have already been made
- Demonstrate loopback waveguides with ring resonators
- Qualify Nitride Waveguides against similar designs
- Lay the groundwork for research to come:
- Get test results showing similar transmission as Eigenmode Solution Simulation of 450nm thick and 1000nm wide



Photonics Overview

- Photonics is the study of transmission and detection of light
- Instead of wires, we have waveguides
- Integrated photonic circuits uses photons and electricity to transmit data
- Integrated photonic circuits branch optical physics and microelectronics



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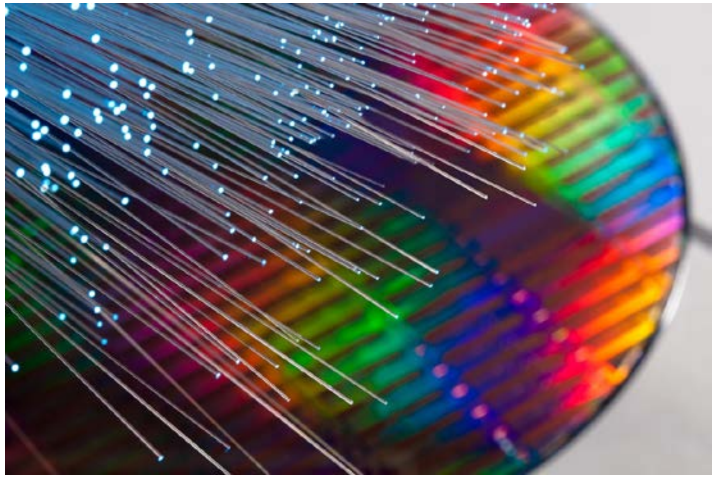

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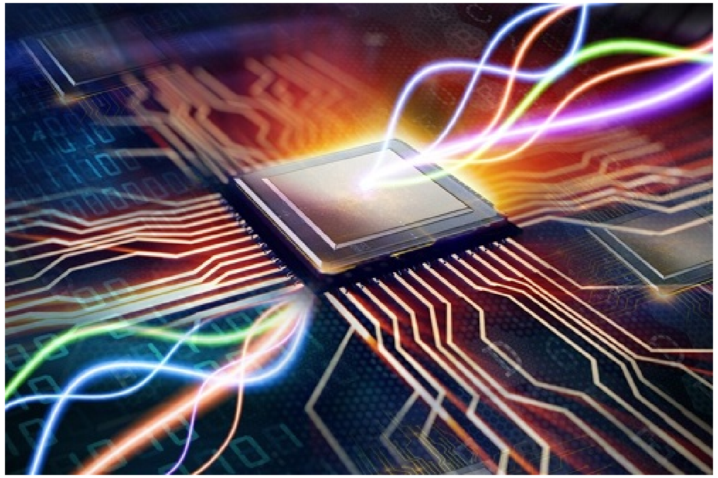
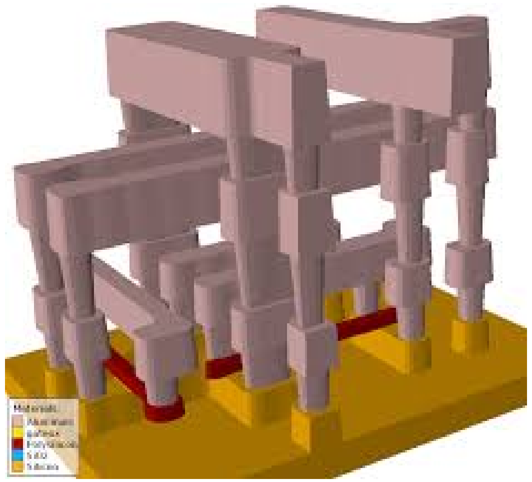


Why Photonics is Needed

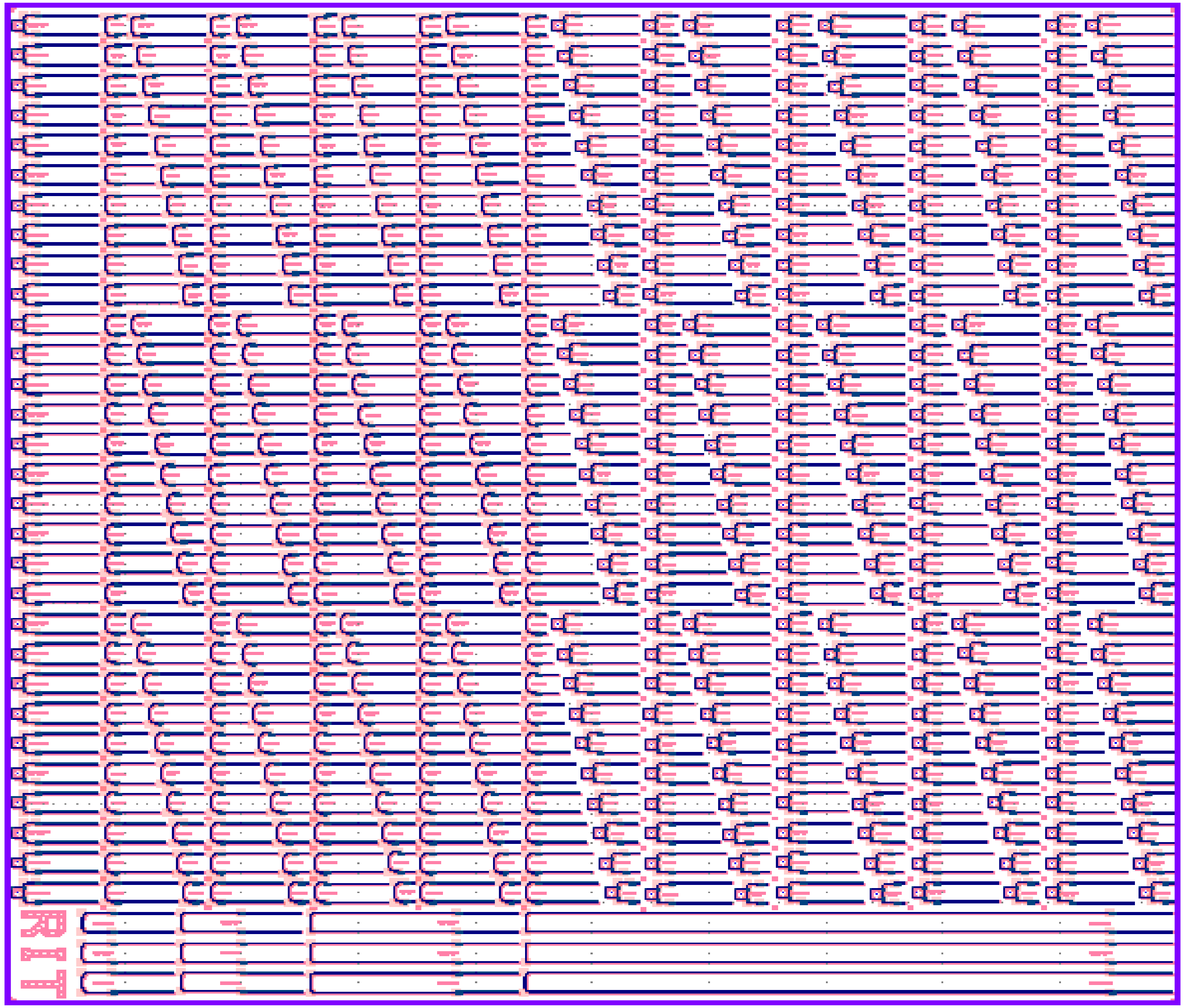
- Electrical interconnects limited in voltage and frequency, driving power consumption up
- Hard to scale due to bandwidth being limited by size
- Photonics allows for high bandwidth and low power consumption
- Data transmission is much faster



Mask Design

Design Variations:

- Loopback Waveguide
  - Varied Grating Coupler Taper
  - Varied Grating Coupler Pitch
  - Varied Waveguide Length
- Ring Resonator Waveguide
  - Varied Grating Coupler Taper
  - Varied Grating Coupler Pitch
  - Varied Resonator Gap



Mask Design

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- Loopback Waveguide ☐
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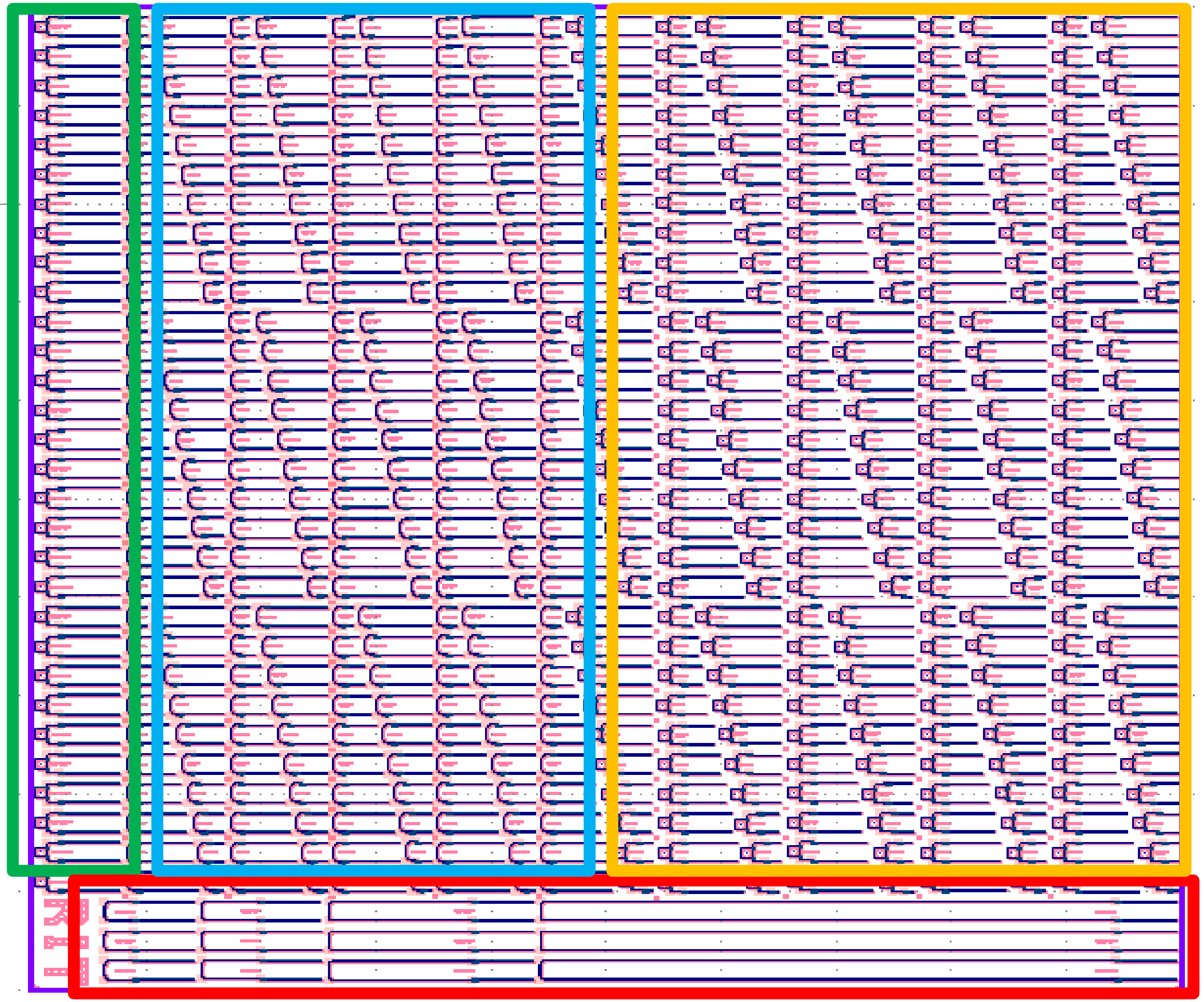
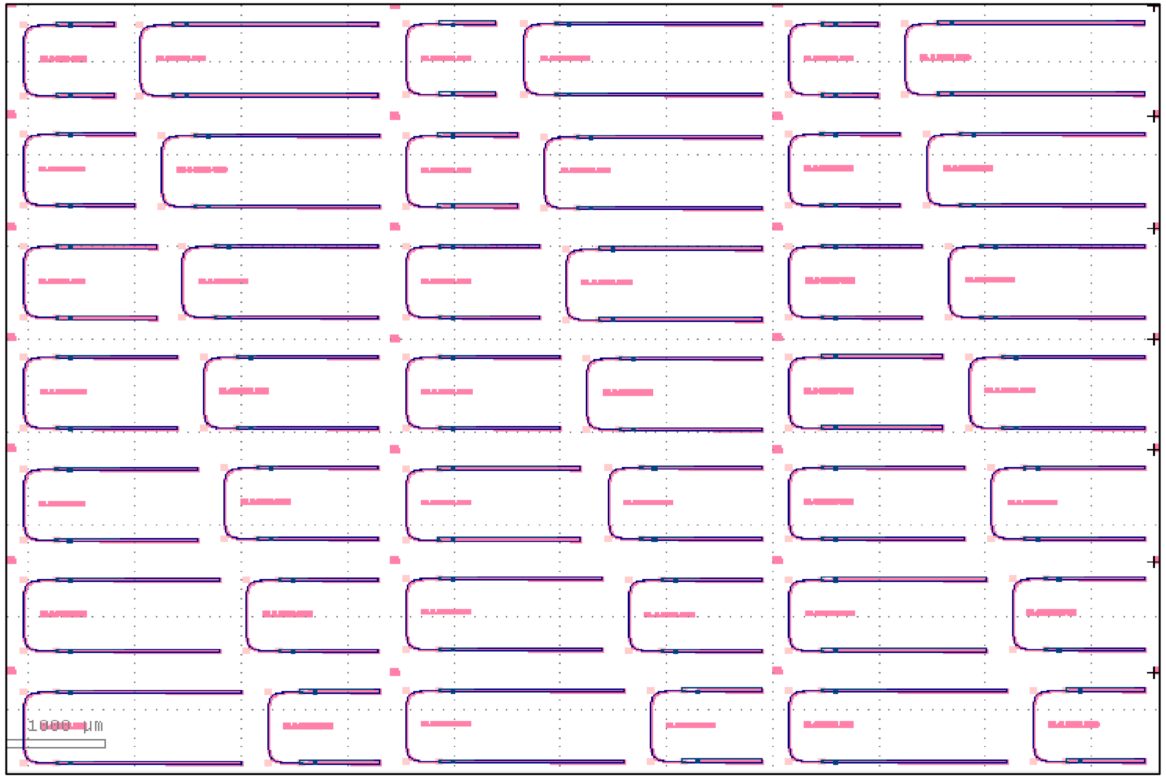
- Ring Resonator Waveguide ☐
    - Varied Grating Coupler Taper
    - Varied Grating Coupler Pitch
    - Varied Resonator Gap ☐



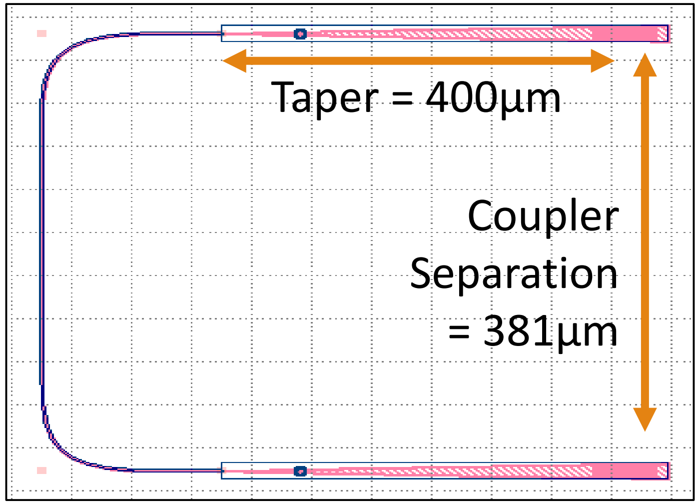
1000nm Width Loopback Waveguides



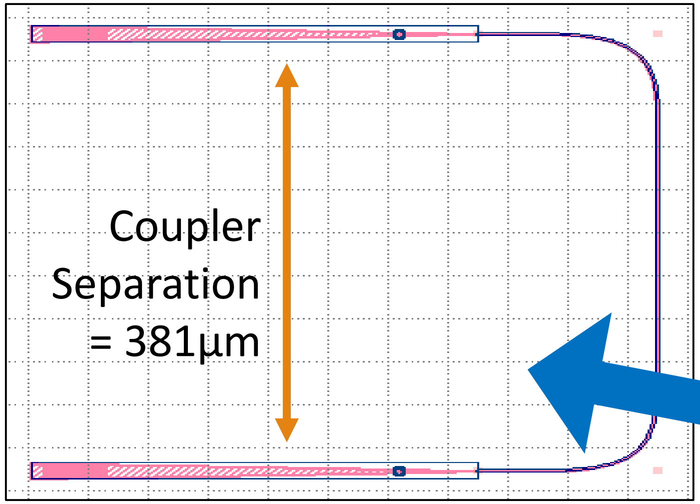
Varied Grating Parameters:

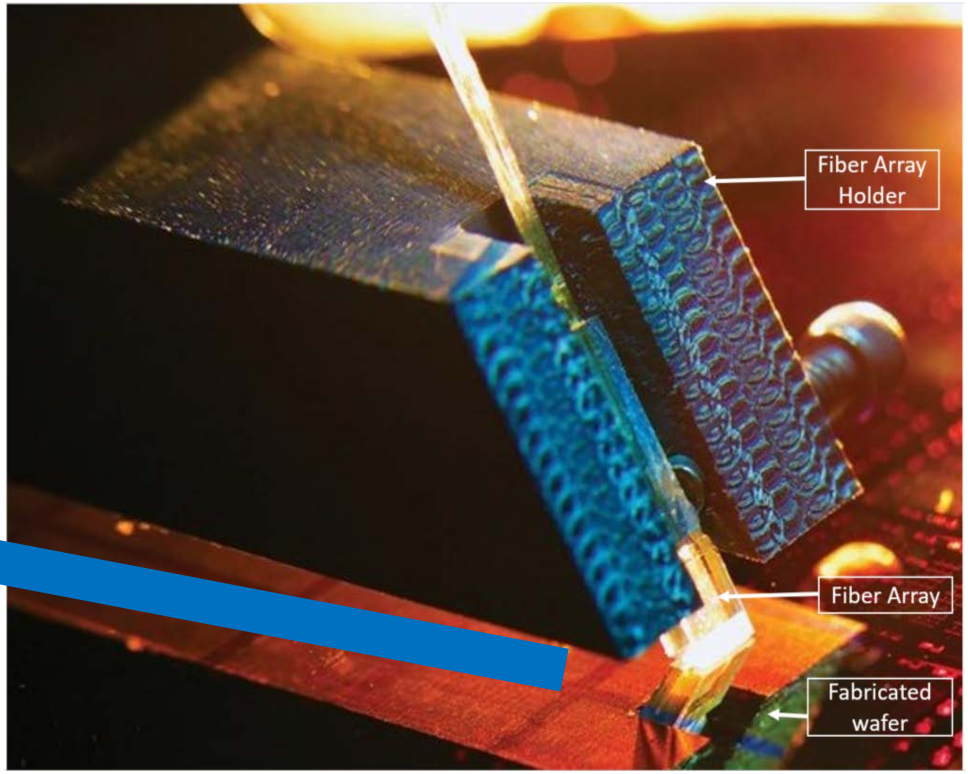
Pitch: 700nm – 1500nm

Taper: 100µm – 1000µm



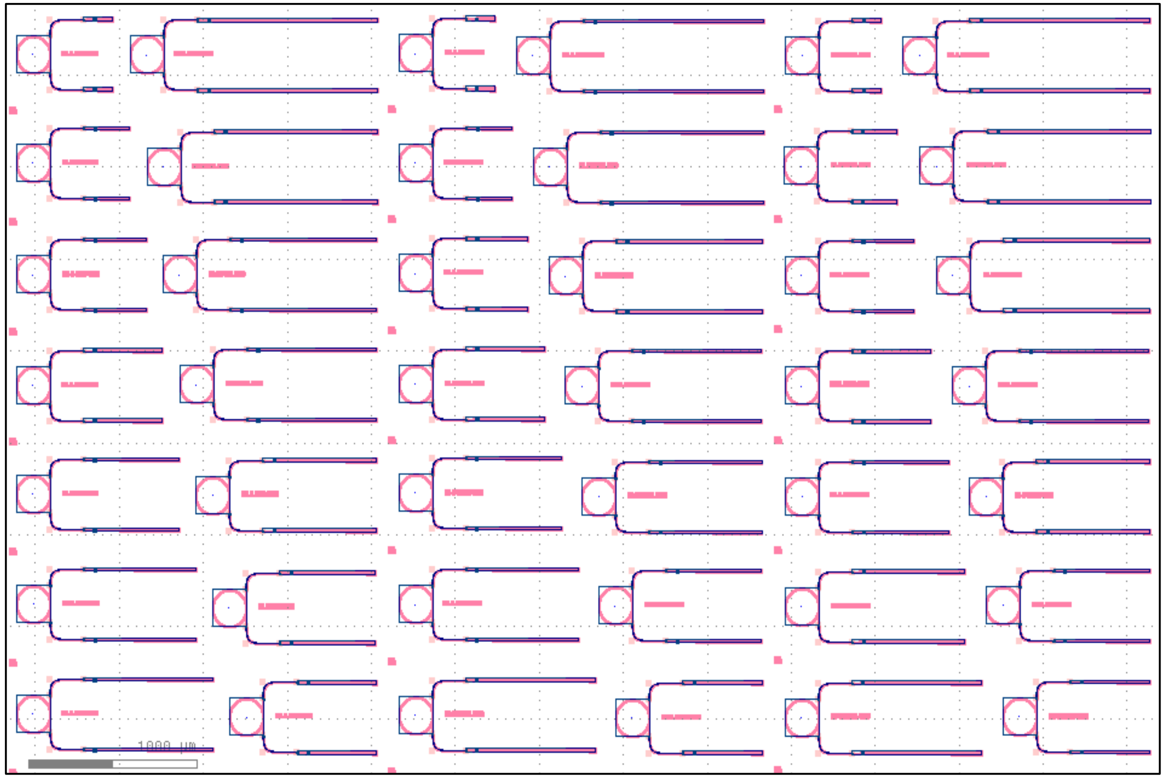
Test Head Setup





[1] Sanjna Lakshminarayanamurthy, 2017

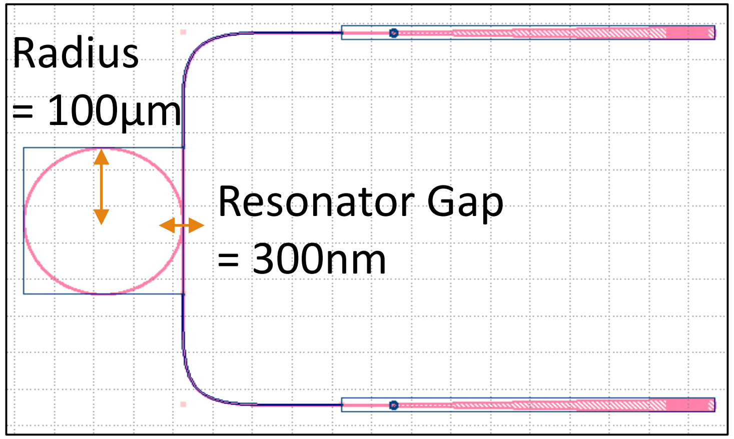
500nm Width Resonator Waveguides



Varied Grating Parameters:

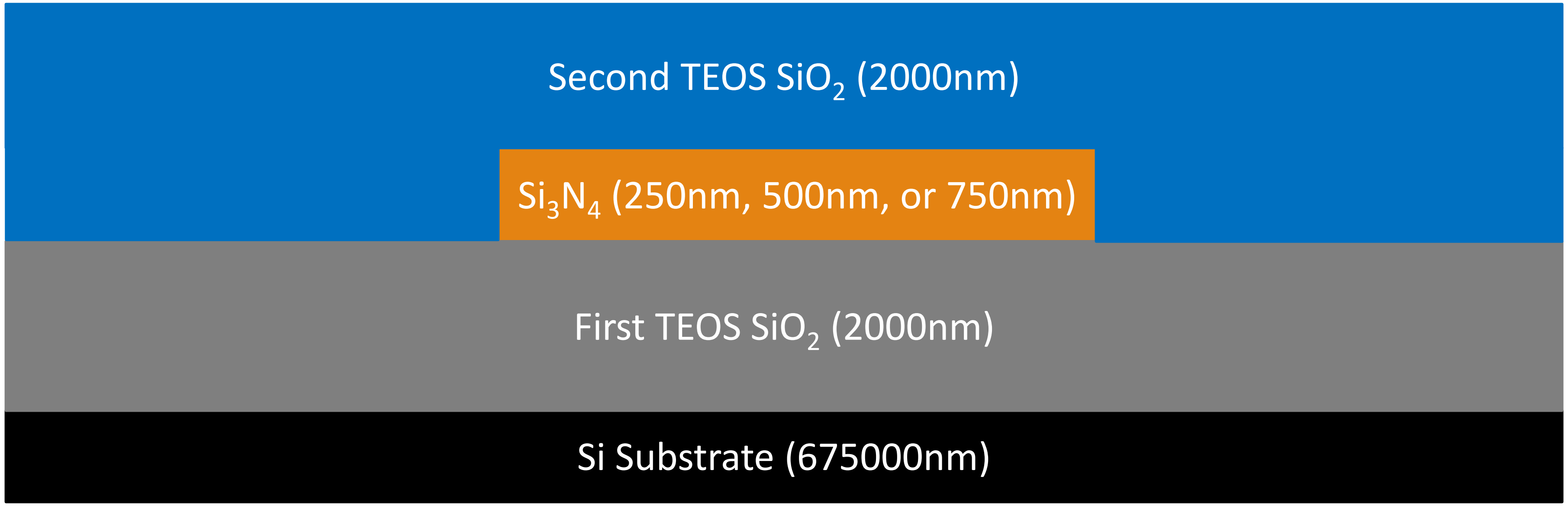
Pitch: 700nm – 1500nm

Taper: 100µm – 1000µm



Process Flow

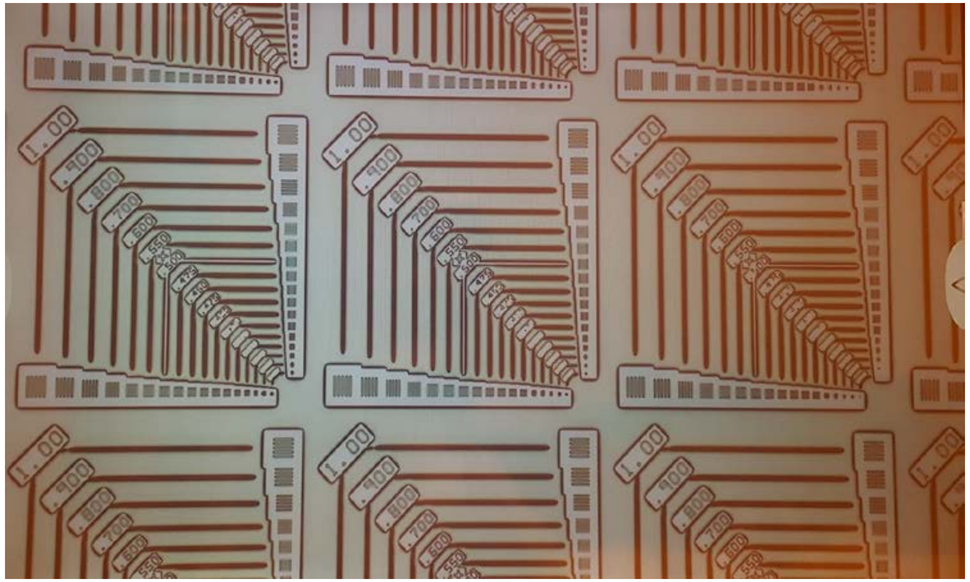
Nitride Critical Dimensions of: 500nm, 1000nm, and 1500nm



1. RCA Clean
2. Oxide Deposition
3. Nitride Deposition
4. Waveguide Pattern
5. Etch
6. Cladding Deposition
7. Test

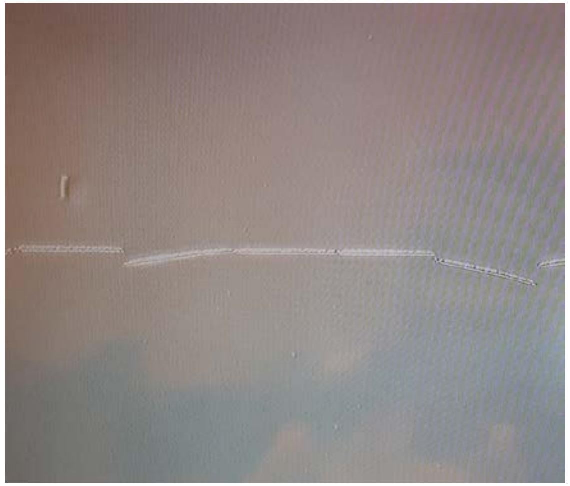
Focus Exposure Matrix

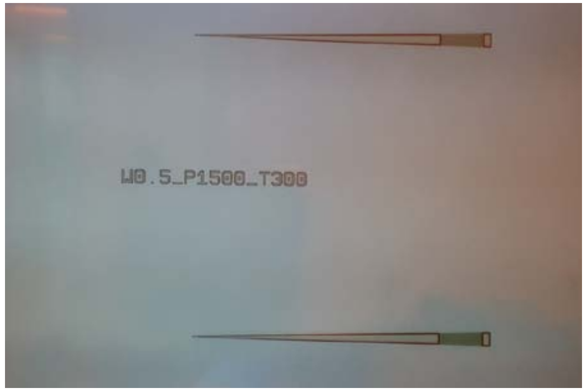
- New film stack being used requires different dose exposure
- New Photoresist being used in the lab: MiR 701
- Typical exposure dose: 275mJ/cm^2
- FEM Exposure variation from 175mJ/cm^2 to 375mJ/cm^2
  - Best exposure dose: 185mJ/cm^2
  - Resolved 0.375µm lines and spaces

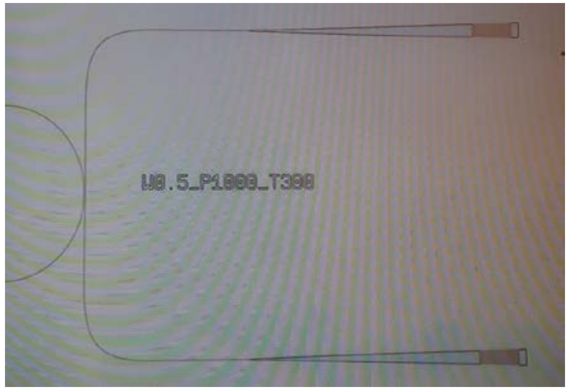


Photoresist Problems

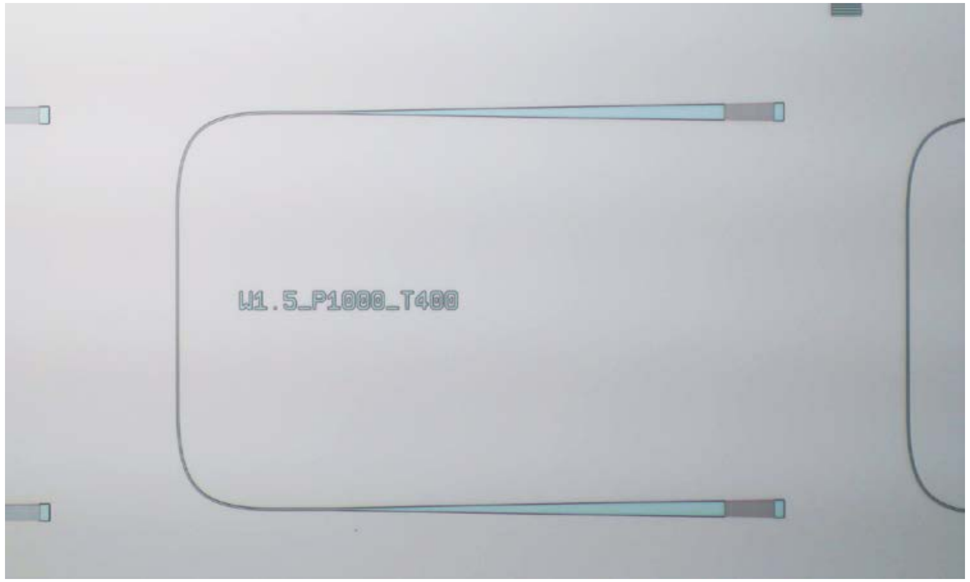
- First photoresist exposure showed poor resolution
- Small photoresist lines not sticking to surface
- Used PRS2000 to chemically strip photoresist and attempted again
- Concluded: Nitride left surface rough
- Chemical strip and rinse did surface preparation that allowed good adhesion



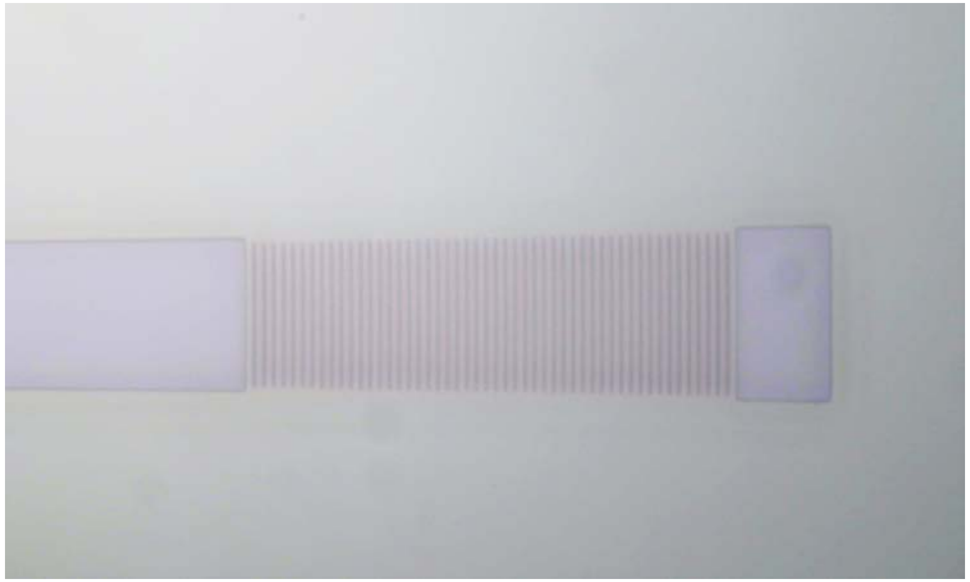




Fabrication Results

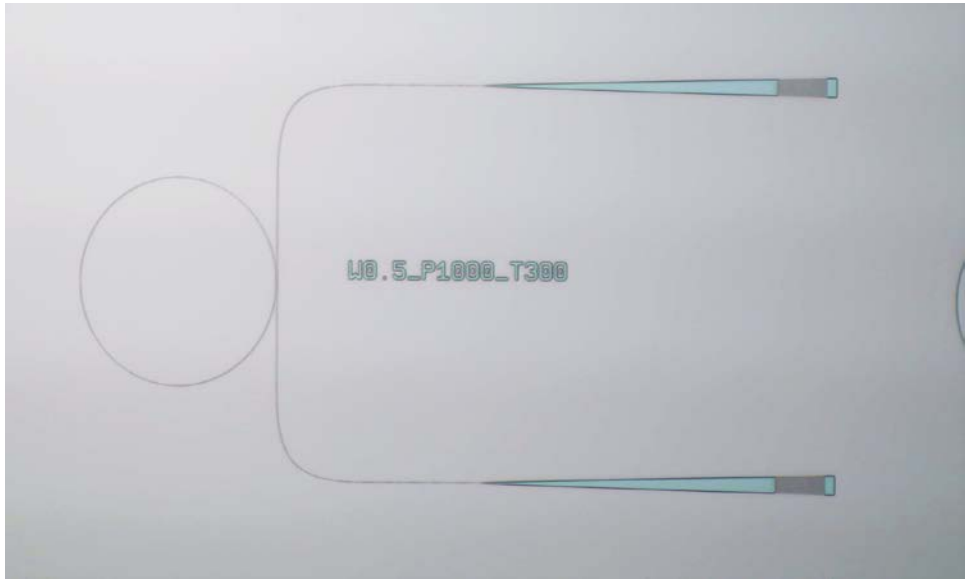


Fabricated Loopback Waveguide with 1.5µm width, 1µm coupler pitch, and 400µm coupler taper



Close up of Grating Coupler showing 0.5µm line and space resolution

Fabrication Results

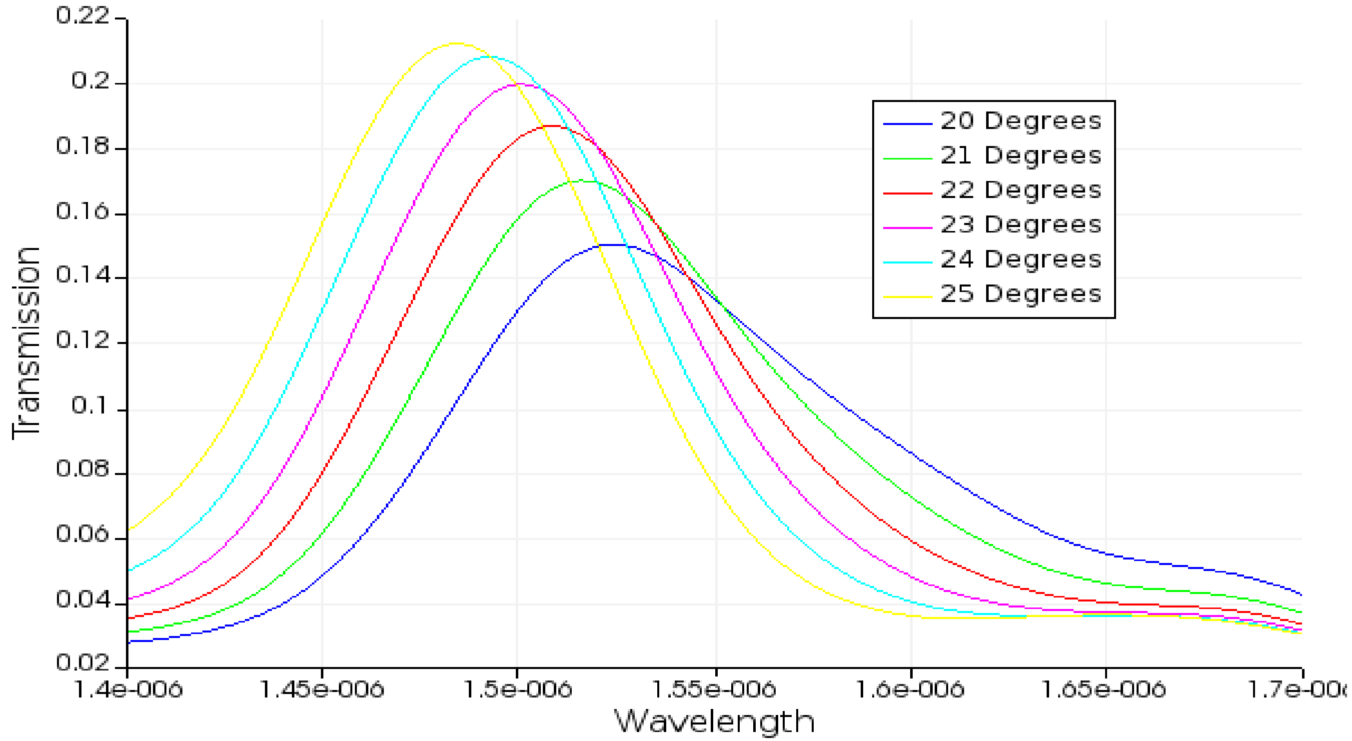


Fabricated Resonator Waveguide with 0.5µm width, 1µm coupler pitch, and 300µm coupler taper

Close up of resonator gap showing 0.3µm space between waveguide and ring

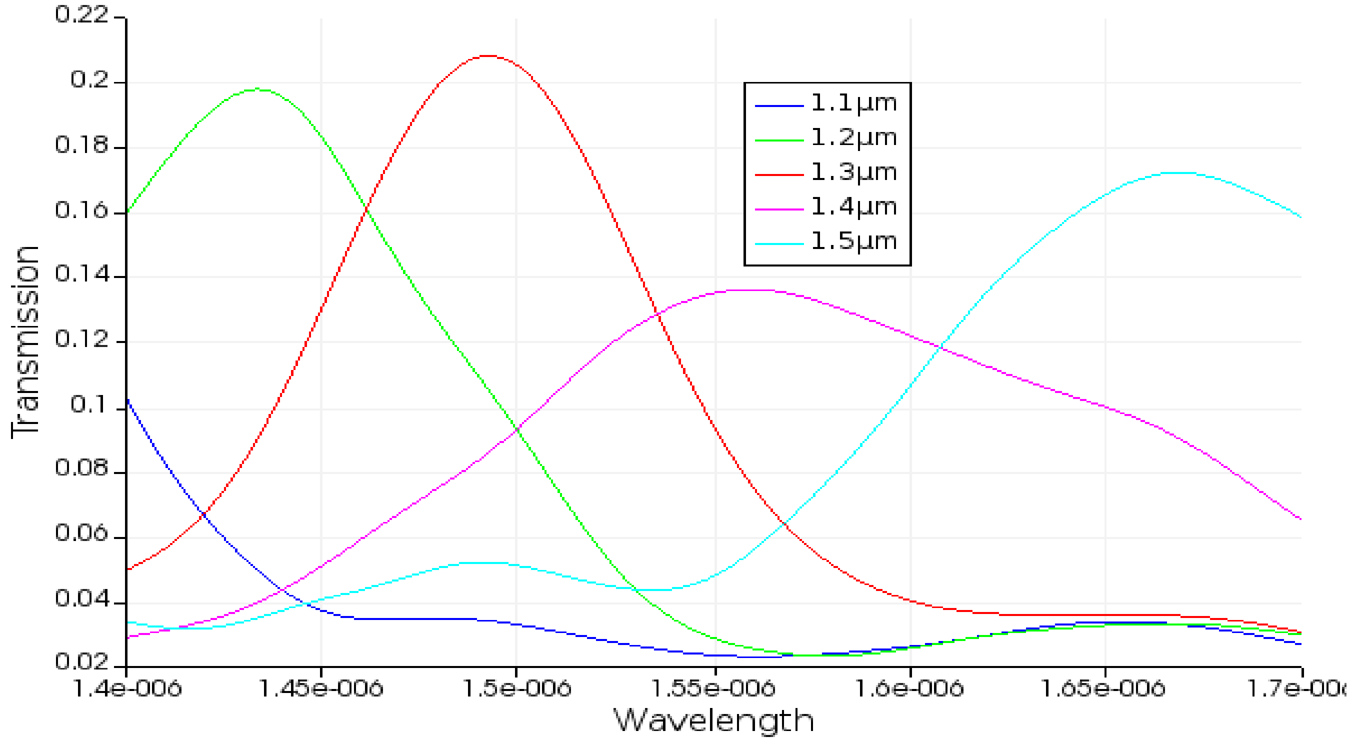
Simulation Results

- Test Head Angle Variation to optimize transmission through Grating Coupler
- Varied from 20 degrees to 30 degrees with best result of 24 degrees



Simulation Results

- Grating Coupler Pitch Variation to optimize transmission
- Varied from 700nm to 1500nm with best result of 1300nm



What’s Next

- **Next Step:** *Physical testing of the fabricated waveguides*

- Improve process to get smaller features
- Project focused more on the fabrication than simulation and optimization
- Simulations for each waveguide to compare the “ideal” to actual
- More simulations to redesign mask and get better transmission and lower loss
- Create a tunable thermo-optic waveguides or CMOS photonic structures

Acknowledgements

- Dr. Preble, Dr. Pearson, and Dr. Ewbank for guidance and help whenever a roadblock was encountered.
- Matt Van Niekerk for helping with simulations.
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- Dr. Fuller for his LPCVD Nitride Recipes and the other recipes developed over the years.